

 <b>SYNOVA</b> Ch. Dent-d'Oche CH-1024 Ecublens Switzerland www.synova.ch	<h1 style="text-align: center;">APPLICATION REPORT</h1>	Report No: 123-8 Sample No: <<box>>
<b>CONFIDENTIAL</b>		

## REPORT:                      W cutting by Laser-MicroJet®

*For*

Anonymous

*By*

Masaki Takano, Synova Japan

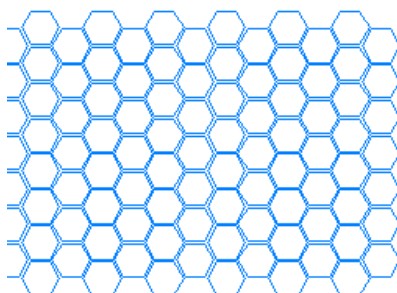
### TASK

The Laser-MicroJet® technology has been tested for W cut below patterns.

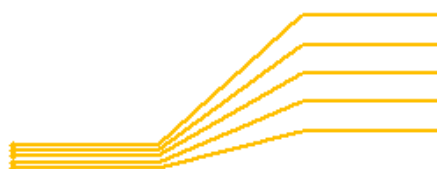
**Pattern1**



**Pattern2**



**Pattern3**



Release of application report			
Project Leader		Responsible Application Group	
Name:	Masaki Takano	Name:	D <sup>r</sup> Benjamin Carron
Date:	2012.03.01	Date:	2012.03.14
Visum:		Visum:	

## Pattern4 / hole drilling

φ0.1

φ0.2



## Pattern5-1 , 5-2 / Tape slit



0.1x 40 0.2P

## SAMPLE DESCRIPTION AND PREPARATION

<b>SAMPLE 1</b>	Material	W
	Dimension	100x100 <i>mm</i>
	Thickness	100 <i>μm</i>
	Quantity	1 <i>pcs</i>



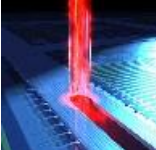
## PROCESS: INSTRUMENT & TEST PARAMETERS

For these experiments, the LDS300M equipped with a green laser has been used as the machine configuration in our lab.

Major advantages of Laser-MicroJet® technology with regards to your application are:

- Cutting of arbitrary shapes
- No chipping on front side, minimal chipping on backside
- Parallel and smooth cut walls

In the table below, the optimized processing parameters used in the experiments are summarized:

	<b>SYSTEM</b>	Machine type	LDS300M
	<b>MICROJET® PARAMETER</b>	Nozzle diameter MicroJet® diameter Water pressure Assist gas	40 $\mu m$ 33.2 $\mu m$ 250 <i>bar</i> He
	<b>LASER PARAMETER</b>	Laser type Wavelength Pulse frequency Average power	L101G 532 <i>nm</i> 8 <i>kHz</i> 10 <i>W</i>
	<b>CUTTING PARAMETER</b>	Cutting speed Number of passes	*1) <i>mm/s</i> *1)
		Fixture	Vacuum chuck

\*1)

	Cutting speed (mm/sec)	Number of passes
Pattern1,2,3,	1	1
Pattern4, $\phi 100\mu m$	0.5	20
Pattern4, $\phi 200\mu m$	10	20
Pattern5	10	5

RESULTS

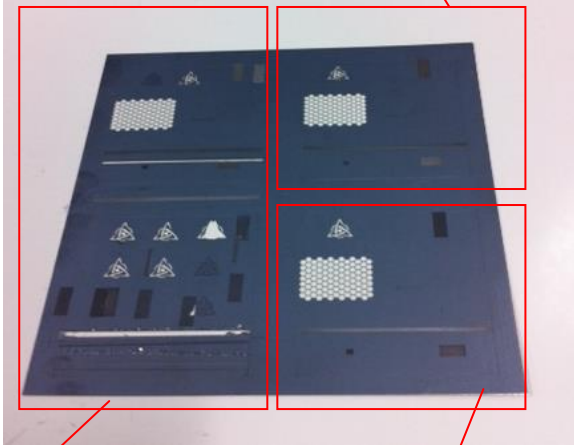
Before cutting



PICTURE: Digital camera image of the sample before processing (bright field illumination; top view)

After cutting

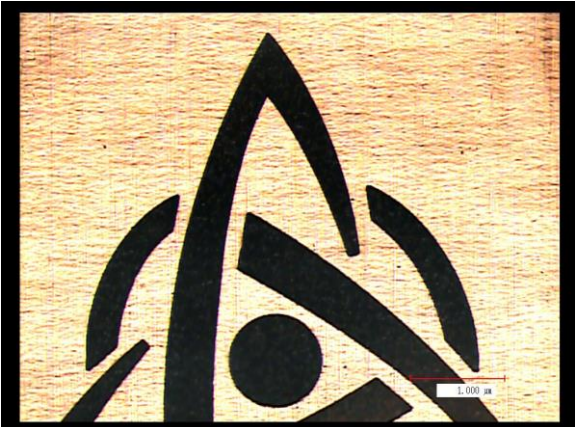
Evaluation 01  
 Pattern1,2,3,4,5-1,5-2



PICTURE: Digital camera image of the sample after processing (bright field illumination; top view)

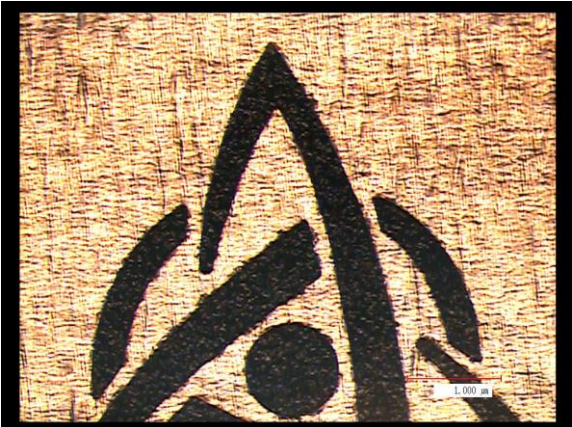
Pattern1

Test cut area

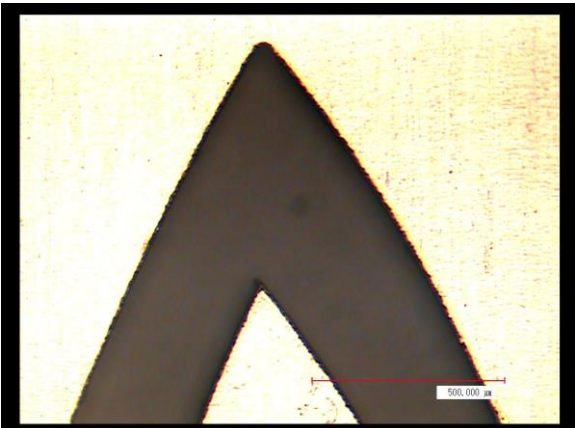


PICTURE: Microscope image of the sample after processing (bright field illumination; top view)

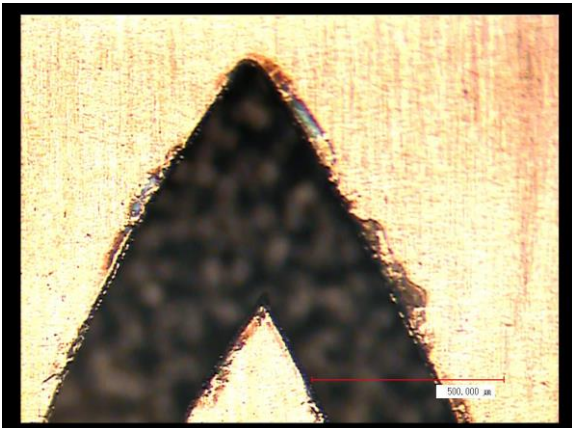
Evaluation 02  
 Pattern1,2,3,4,5-2,6-2



PICTURE: Microscope image of the sample after processing (bright field illumination; back view)



PICTURE: Microscope image of the sample after processing (bright field illumination; top view)



PICTURE: Microscope image of the sample after processing (bright field illumination; back view)



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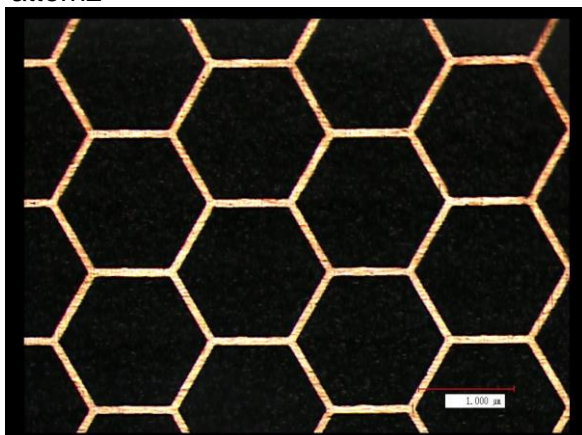
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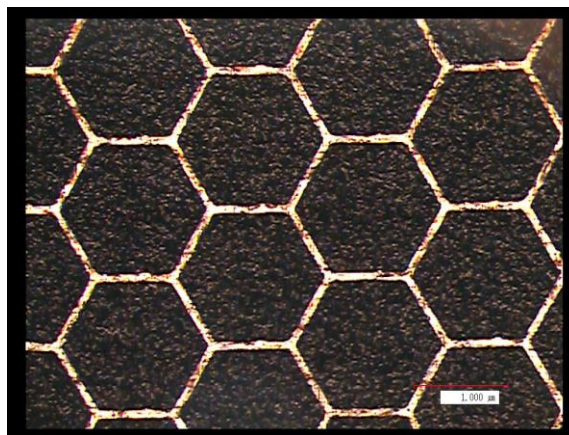
Sample No: <<box>>

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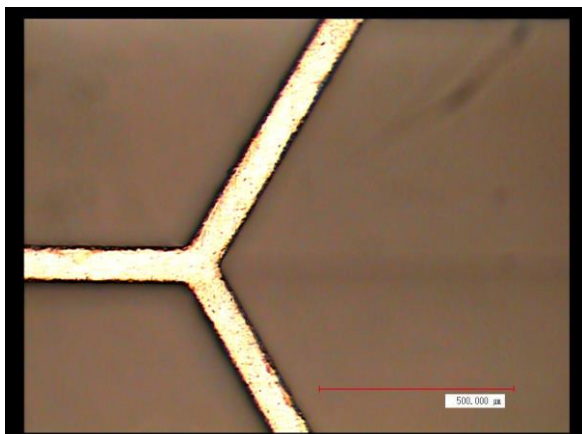
## Pattern2



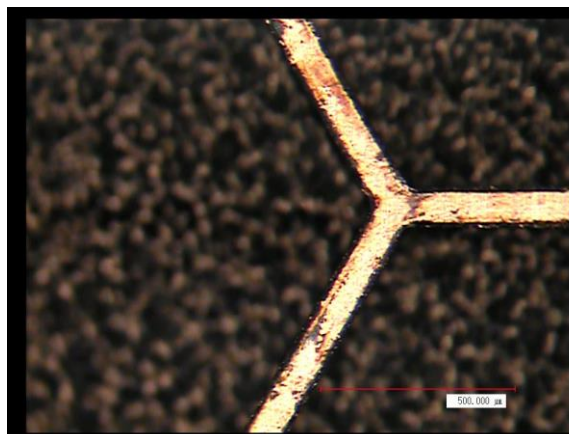
**PICTURE:** Microscope image of the sample after processing (bright field illumination; top view)



**PICTURE:** Microscope image of the sample after processing (bright field illumination; back view)



**PICTURE:** Microscope image of the sample after processing (bright field illumination; top view)



**PICTURE:** Microscope image of the sample after processing (bright field illumination; back view)



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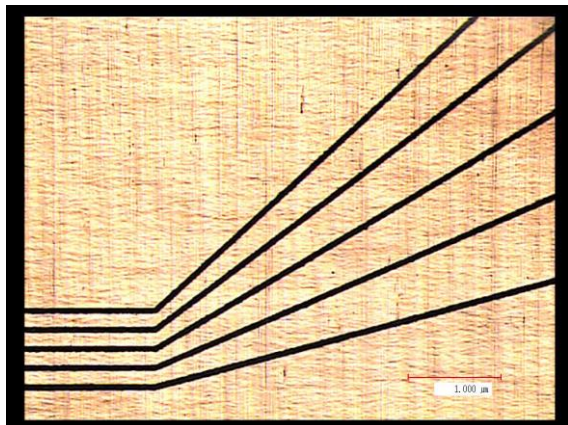
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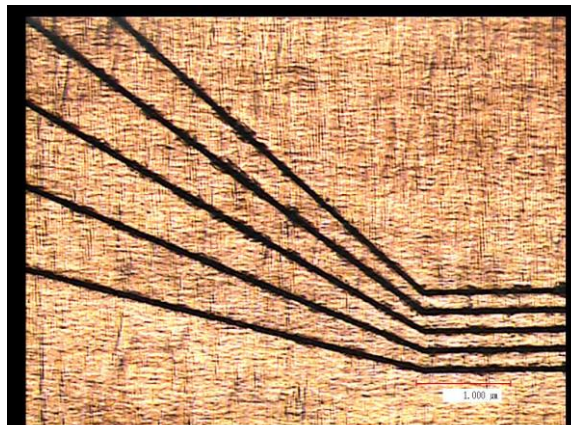
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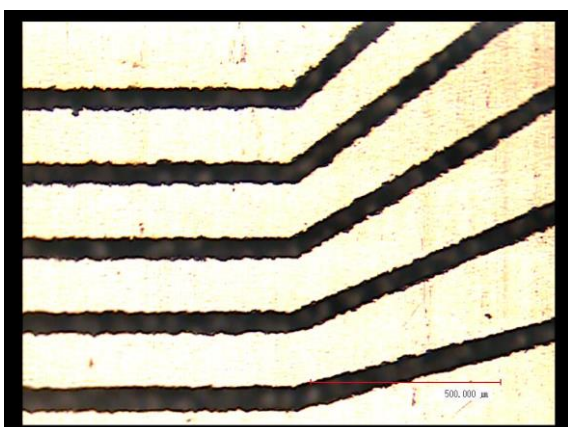
## Pattern3



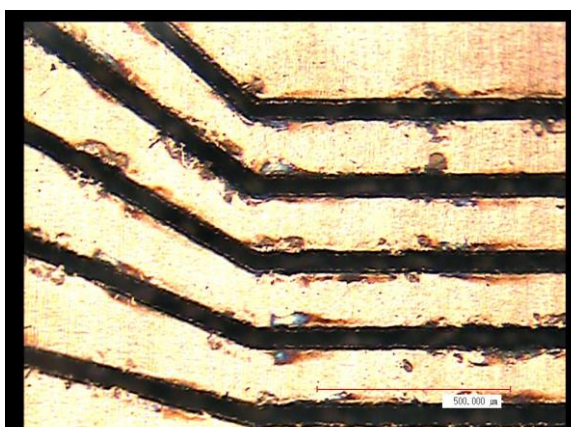
**PICTURE:** Microscope image of the sample after processing (bright field illumination; top view)



**PICTURE:** Microscope image of the sample after processing (bright field illumination; back view)



**PICTURE:** Microscope image of the sample after processing (bright field illumination; top view)



**PICTURE:** Microscope image of the sample after processing (bright field illumination; back view)



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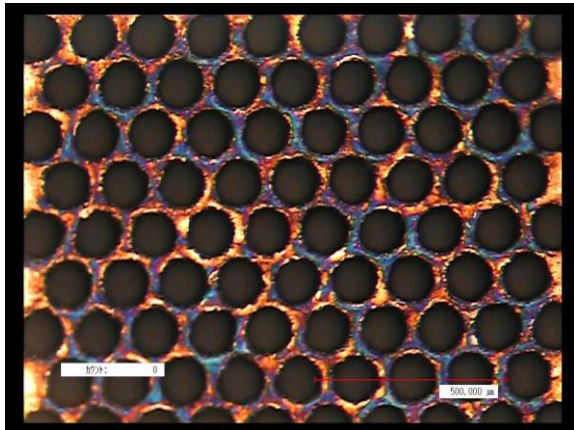
Report No: 123-8

Sample No: <<box>>

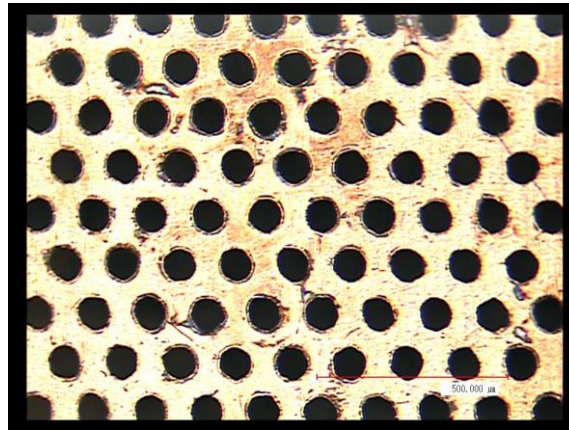
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## Pattern4

100um holes

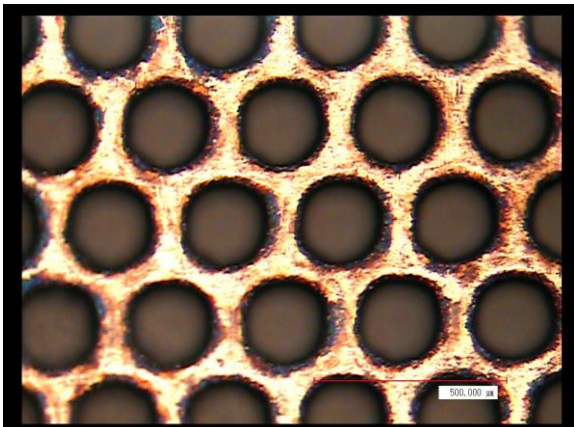


**PICTURE:** Microscope image of the sample after processing (bright field illumination; top view)

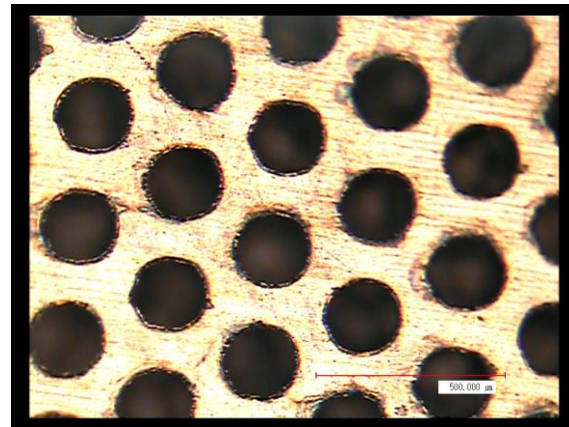


**PICTURE:** Microscope image of the sample after processing (bright field illumination; back view)

200um holes

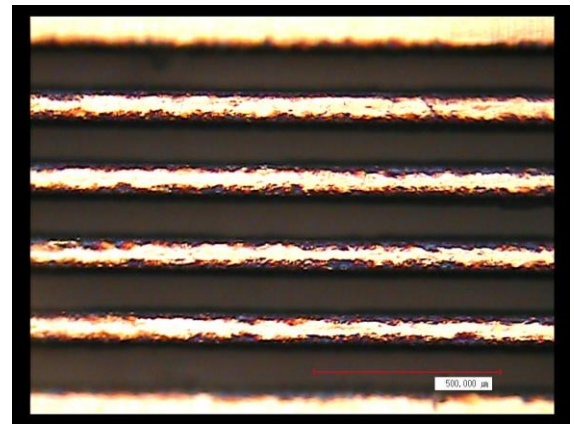


**PICTURE:** Microscope image of the sample after processing (bright field illumination; top view)

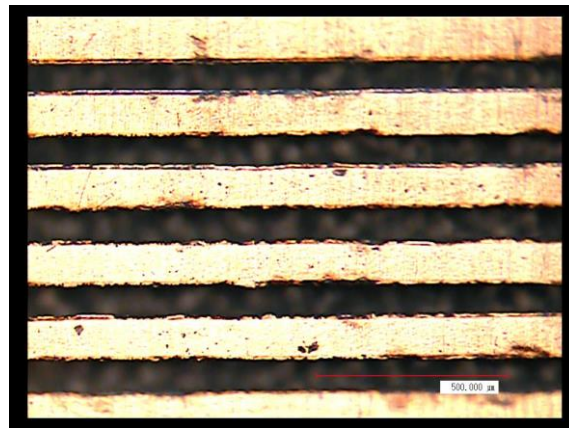


**PICTURE:** Microscope image of the sample after processing (bright field illumination; back view)

## Pattern5



**PICTURE:** Microscope image of the sample after processing (bright field illumination; top view)



**PICTURE:** Microscope image of the sample after processing (bright field illumination; back view)

We cleaned this sample plate with ultrasonic bath for 5min after processing.

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The table below summarized Anonymous expectations and our results

	What are your priorities? (please put a cross)	Quantified expectations or improvements
<ul style="list-style-type: none"> <li>Burr-free:</li> </ul>	2	Negligible
<ul style="list-style-type: none"> <li>Chipping/Cracks:</li> </ul>	1	Neither chipping nor crack

## CONCLUSION

The W sample was investigated on SYNOVA LDS300 machine. This machine is based on the MicroJet® technology and combines the advantages the high energy pulsed laser with a hair-thin water jet.

We cut various geometries and the overall quality is good, sharp edge, no chipping and crack, negligible small burr, nevertheless we observed discoloration on the front side of the small holes (Pattern 4).

We thank you for your interest in our technology and we hope our results meet your requirements. Our sales will contact you soon to obtain a feedback about the analysis of these results and to discuss with you the further steps.